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APPLICATION NO.	F	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/665,313		09/11/2003	Michael Goldstein	Intel 10559-869001 / P173	5451
20985	7590	04/21/2005		EXAMI	NER
	ISH & RICHARDSON, PC 2390 EL CAMINO REAL			TUROCY, I	DAVID P
SAN DIEG				ART UNIT	PAPER NUMBER
	,			1762	
				DATE MAILED: 04/21/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

·	Application No.	Applicant(s)	
Office Andien Summer	10/665,313	GOLDSTEIN, MICHAEL	
Office Action Summary	Examiner	Art Unit	
The MAN MO DATE And the construction of the co	David Turocy	1762	
The MAILING DATE of this communication appeared for Reply	opears on the cover sheet w	ith the correspondence address	
A SHORTENED STATUTORY PERIOD FOR REP THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a re If NO period for reply is specified above, the maximum statutory perior Failure to reply within the set or extended period for reply will, by statu. Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b).	.136(a). In no event, however, may a ply within the statutory minimum of thi d will apply and will expire SIX (6) MO tte, cause the application to become A	reply be timely filed rty (30) days will be considered timely. NTHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).	
Status			
1) ☐ Responsive to communication(s) filed on <u>07.</u> 2a) ☐ This action is FINAL . 2b) ☐ Th 3) ☐ Since this application is in condition for allow closed in accordance with the practice under	is action is non-final. ance except for formal mat	·	
Disposition of Claims			
 4) Claim(s) 1-17 is/are pending in the application 4a) Of the above claim(s) 13-17 is/are withdrases 5) Claim(s) is/are allowed. 6) Claim(s) 1-9, 11-12 is/are rejected. 7) Claim(s) 10 is/are objected to. 8) Claim(s) are subject to restriction and an are subject to restriction and are subject. 	awn from consideration.		
Application Papers			
9) The specification is objected to by the Examir	ccepted or b) objected to e drawing(s) be held in abeya ection is required if the drawing	nce. See 37 CFR 1.85(a). g(s) is objected to. See 37 CFR 1.121(d).	
Priority under 35 U.S.C. § 119		·	
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents. 2. Certified copies of the priority documents. 3. Copies of the certified copies of the priority documents. * See the attached detailed Office action for a list. 	nts have been received. nts have been received in a iority documents have been au (PCT Rule 17.2(a)).	Application No n received in this National Stage	
Attachment/c)			
 Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/0 Paper No(s)/Mail Date 9/11/2003. 	Paper No	Summary (PTO-413) (s)/Mail Date Informal Patent Application (PTO-152) 	

U.S. Patent and Trademark Office PTOL-326 (Rev. 1-04)

DETAILED ACTION

Election/Restrictions

1. Applicant's election without traverse of Group I, claims 1-12, in the reply filed on 4/7/2005 is acknowledged. Claims 13-17 withdrawn from further consideration.

Claim Rejections - 35 USC § 112

- The following is a quotation of the second paragraph of 35 U.S.C. 112:
 The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 3. Claim 7 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.
- 4. Claim 7 recites the limitation "the carrier" in line 2. There is insufficient antecedent basis for this limitation in the claim. The claim depends from claim 1, which does not recite "a carrier". For the purposes of applying art, the examiner is going to interpret claim 7 to depend from claim 6.

Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

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6. Claims 1, 4, 6-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over US Patent 6444984 by Lundgren et al., hereafter Lundgren in view of US Patent 6619903 by Friedman et al., hereafter Friedman.

Lundgren discloses spraying carbon dioxide snow onto the surface of a transmissive substrate to form a solid carbon dioxide layer on the surface, which is cooled below the sublimation temperature of the carbon dioxide prior to forming the layer (abstract, Column 6, lines 58-63). The carbon dioxide coating as taught by Lundgren inherently prevents particles from contacting the surface. Lundgren discloses the substrate is in a carrier maintained at a temperature below the sublimation temperature of carbon dioxide (Column 6, lines 58-63). Lundgren discloses applying the carbon dioxide coating within the tool used to direct radiation. Lundgren discloses raising the temperature around the substrate above the carbon dioxide sublimation temperature to remove the coating from the substrate (Column 7, lines 35-40).

Lundgren fails to disclose applying the carbon dioxide film to a reticle. However, Friedman discloses transmissive substrates, such as reticles, are often used in lithography tools (Column 1, lines 18-21). Friedman discloses reticles, which are within an enclosure, are transported in a carrier and then inserted within the lithography tool (Column 2, lines 23-44).

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to modify Lundgren to use a transmissive reticle within a lithography tool as suggested by Friedman to provide a desirable carbon dioxide coating

on a substrate because Lundgren discloses applying a solid carbon dioxide film onto the surface of a transmissive substrate and Friedman discloses reticles, which are used in lithography tools, are known transmissive substrate.

Claim 11: Lundgren in view of Friedman fails to disclose reflecting radiation off of the surface of the reticle in a lithography tool.

Friedman discloses using transmissive reticles within a lithography tool to transfer a desired pattern onto a substrate by allowing lithographic wavelengths to pass through (Column 1, lines 18-23). Friedman discloses also using reflective reticles in place of transmissive reticles within a lithograph tool (Column 1, lines 45-48). Friedman discloses reflective reticles are used for short wavelengths, which would otherwise be absorbed by the transmissive reticle (Column 1, lines 45-48).

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to modify Lundgren in view of Friedman to use the reflective reticle as suggested by Friedman to provide a desirable reflection of wavelengths within a lithography tool because Lundgren in view of Friedman discloses coating a transmissive reticle and Friedman discloses reflective reticles are known in the art as substitutes for transmissive within a lithography tool.

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7. Claims 2 and 3 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lundgren in view of Friedman as applied to claim 1 above and further in view of Applied Surface Technologies.

Claim 2: Lundgren in view of Friedman discloses all the limitations of these claims as discussed above, but fails to disclose spraying the reticle with carbon dioxide snow to remove particles from the surface.

However, Applied Surface Technologies discloses cleaning glass and optical surfaces to remove contamination before applying a coating to the surface (Glass and Optics, paragraph 1). Applied Surface Technologies discloses aiming the carbon dioxide snow nozzle at an angle so that the contamination removed does not land on the cleaned area (Cleaning Issues, Methods).

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to modify Lundgren in view of Friedman to use the carbon dioxide snow cleaning as suggested by Applied Surface Technology to provide a desirable optical substrate because Applied Surface Technology discloses spraying carbon dioxide snow on a surface is known in the art to remove contamination from optical substrates prior to coating and therefore would reasonably be expected to effectively provide a reticle with a contaminant free surface prior to coating.

Claim 3: Lundgren in view of Friedman and further in view of Applied Surface
Technologies fails to discloses spraying carbon dioxide snow at a grazing angle with

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Therefore it would have been obvious to one skill in the art at the time of the invention was made to determine the optimal value for the spraying angle, including at a grazing angle, used in the process of Lundgren in view of Friedman and further in view of Applied Surface Technologies, through routine experimentation, to effectively prevent the removed contaminants from redopositing on the surface of the substrate.

8. Claim 5 is rejected under 35 U.S.C. 103(a) as being unpatentable over Lundgren in view of Friedman as applied to claim 1 above and further in view of US Patent 4806455 by LaBianca, hereafter LaBianca

Lundgren in view of Friedman teaches all the limitations of these claims as discussed above. However, they fail to disclose spraying the carbon dioxide snow at a substantially 90-degree angle with respect to the surface of the reticle.

However, LaBianca discloses spraying at 90 degrees relative to the surface of a substrate is a known method of providing a coating on a substrate (Figure 3).

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to modify Lundgren in view of Friedman to spray the coating at 90 degrees relative to the substrate surface as suggested by LaBianca to provide a desirable coating on a substrate because LaBianca discloses spraying at 90 degrees relative to the surface is known in the art to provide coating on a substrate and therefore

would reasonably be expected to effectively provide a carbon dioxide coating on a reticle.

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9. Claim 12 rejected under 35 U.S.C. 103(a) as being unpatentable over Lundgren in view of Friedman as applied to claim 11 above and further in view of US Patent 6835503 by Krauth, hereafter Krauth.

Lundgren in view of Friedman teaches all the limitations of these claims as discussed above. However, they fail to disclose reflecting extreme ultraviolet radiation off of the surface of the reticle in a lithography tool.

However, Krauth discloses that it is known in the art to reflect extreme ultraviolet radiation using a reticle within a lithography tool (Column 1, lines 13-46). Krauth discloses that the wavelength of light transmitted through or reflected by the reticle is critical during the lithography process (Column 1, lines 26-29).

Therefore, it would have been obvious to one of ordinary skill in the art at the time of the invention to modify Lundgren in view of Friedman to reflect extreme ultraviolet radiation as suggested by Krauth because Krauth discloses reflective reticles are known in the art to reflect extreme ultraviolet radiation in a lithography tool and Lundgren in view of Friedman discloses using a reflective reticle within a lithography tool and therefore would reasonably be expected to effectively reflect extreme ultraviolet radiation.

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Allowable Subject Matter

10. Claim 10 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

11. The following is a statement of reasons for the indication of allowable subject matter:

Claim 10: None of the prior art cited or reviewed by the examiner teach or reasonably suggest application of the carbon dioxide film to the reticle while inside the lithography tool.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to David Turocy whose telephone number is (571) 272-2940. The examiner can normally be reached on Monday-Friday 8:30-6:00, No 2nd Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Timothy Meeks can be reached on (571) 272-1423. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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David Turocy AU 1762

TIMOTHY MEEKS
SUPERVISORY PATENT EXAMINER